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| APPLICATION NO. | FILING DATE                                 | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO.     | CONFIRMATION NO. |
|-----------------|---|----------------------|-------------------------|------------------|
| 10/024,782      | 12/19/2001                                  | Masaji Shinjo        | JP000033                | 3212             |
| 24737           | 7590 04/22/2004                             |                      | EXAMINER                |                  |
| PHILIPS IN      | TELLECTUAL PROI                             | ERDEM, FAZLI         |                         |                  |
|                 | P.O. BOX 3001<br>BRIARCLIFF MANOR, NY 10510 |                      | ART UNIT                | PAPER NUMBER     |
|                 |   |                      | 2826                    |                  |
|                 |   |                      | DATE MAILED: 04/22/2004 |                  |

Please find below and/or attached an Office communication concerning this application or proceeding.

| i,  |  |   |  |  |  |  |
|---|--|---|--|--|--|--|
|   | Application No.  | Applicant(s)  |  |  |  |  |
|   | 10/024,782   | SHINJO, MASAJI  |  |  |  |  |
| Office Action Summary   | Examiner   | Art Unit  |  |  |  |  |
|   | Fazli Erdem  | 2826  |  |  |  |  |
| The MAILING DATE of this communication app<br>Period for Reply  | ears on the cover sheet with the c   | orrespondence address   |  |  |  |  |
| A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).   | 6(a). In no event, however, may a reply be tim<br>within the statutory minimum of thirty (30) days<br>ill apply and will expire SIX (6) MONTHS from<br>cause the application to become ABANDONEI | ely filed  will be considered timely. the mailing date of this communication.  (35 U.S.C. § 133). |  |  |  |  |
| Status  |  |   |  |  |  |  |
| 2a) ☐ This action is <b>FINAL</b> . 2b) ☐ This 3) ☐ Since this application is in condition for allowant   | ☐ This action is <b>FINAL</b> . 2b)☐ This action is non-final.   |   |  |  |  |  |
| Disposition of Claims   |  |   |  |  |  |  |
| 4) ☐ Claim(s) 1-8 and 10-20 is/are pending in the ap 4a) Of the above claim(s) is/are withdraw 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1-3,5,7,8,10,11,15 and 18 is/are reject 7) ☐ Claim(s) 4,6,12-14,16,17,19 and 20 is/are object 8) ☐ Claim(s) are subject to restriction and/or  | vn from consideration. ted. cted to.   |   |  |  |  |  |
| Application Papers  |  |   |  |  |  |  |
| 9) The specification is objected to by the Examiner 10) The drawing(s) filed on is/are: a) access Applicant may not request that any objection to the of Replacement drawing sheet(s) including the correction of the original transfer of or the original transfer of the original transfer or the | epted or b) objected to by the Edrawing(s) be held in abeyance. See on is required if the drawing(s) is obj  | ected to. See 37 CFR 1.121(d).  |  |  |  |  |
| Priority under 35 U.S.C. § 119  |  |   |  |  |  |  |
| 12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:  1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the prior application from the International Bureau * See the attached detailed Office action for a list of  | s have been received. s have been received in Application ity documents have been received (PCT Rule 17.2(a)).   | on No<br>ed in this National Stage  |  |  |  |  |
| Attachment(s)   |  |   |  |  |  |  |
| <ol> <li>Notice of References Cited (PTO-892)</li> <li>Notice of Draftsperson's Patent Drawing Review (PTO-948)</li> <li>Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)         Paper No(s)/Mail Date     </li> </ol>  | 4)   |   |  |  |  |  |

Art Unit: 2826

#### **DETAILED ACTION**

### Allowable Subject Matter

1. Claims 4, 6, 12, 13, 14, 16, 17, 19 and 20 objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1-3, 5, 7, 10 and 11 rejected under 35 U.S.C. 103(a) as being unpatentable over Yamanaka et al. (6,452,653) in view of Jang et al. (6,522,375) further in view of Goto et al. (JP 11-183730) further in view of Korishima et al. (JP 9-288274) further in view of Broeng et al. (6,539,155) further in view of Yamamoto et al. (6,407,786) further in view of Tsuda et al. (6,097,458).

Regarding Claims 1-3, 5, 7, 10, 11, Yamanaka et al. disclose reflector, method of fabricating the same, reflective display device comprising reflector, and method of fabricating the same where a reflector comprises a substrate provided with a plurality of projecting and depressed structures which are groups of columnar portions each serving as a basic unit and composed of plurality of minute columnar portions, which are separate from each other or at least partially connected to each other, and with a light reflecting thin film provided over the

Art Unit: 2826

projecting and depressed structures. The reflective display device has a liquid crystal layer provided between a pair of substrates. One of the pair of substrates is provided with projecting and depressed portions covered with a metal film and with a support portion for supporting the counter substrate, which are molded integrally. Yamanaka et al. fail to disclose the required projecting and depressions, the required shape configuration, the required shape configuration in the required manner, the required vertex structure, required vertex structure in proper configuration and the required polygon structure. However, Jang et al. disclose a reflection type liquid crystal display and a method for fabricating the same where the required projecting and depression structure are disclosed. Furthermore, Goto et al. disclose a light guide plate, surface light source using the light guide plate and liquid crystal display device where the required shape structure is disclosed. Korishima et al. disclose a liquid crystal display structure where the required shape structure in the required manner is disclosed. Additionally, Broeg et al. disclose microstructured optical fibres where the required vertex structure is disclosed. Finally, Yamamoto et al. disclose a liquid crystal display device and method of fabricating the same where the required vertex structure in the required configuration is disclosed. Tsuda et al. disclose disclose a reflector, reflective liquid crystal display incorporating the same and the method for fabricating the same where in claim 31 the required polygon structure is disclosed.

It would have been obvious to one of having ordinary skill in the art at the time the invention was made to include the required projecting and depression structures, the required shape structure, the required shape structure in the required manner, the required vertex structure, the required vertex structure in the required configuration and the required polygon structure in Yamanaka et al. as taught by Jang et al., Goto et al., Korishima et al., Broeng et al., Yamamoto

Art Unit: 2826

and Tsuda et al. respectively in order to have a liquid crystal display device with better performance.

3. Claims 8, 15 and 18 rejected under 35 U.S.C. 103(a) as being unpatentable over Yamanaka et al. (6,452,653) in view of Jang et al. (6,522,375) further in view of Goto et al. (JP 11-183730) further in view of Korishima et al. (JP 9-288274) further in view of Tsuda et al. (6,097,458).

Regarding Claims 8, 15, and 18, Yamanaka et al. disclose reflector, method of fabricating the same, reflective display device comprising reflector, and method of fabricating the same where a reflector comprises a substrate provided with a plurality of projecting and depressed structures which are groups of columnar portions each serving as a basic unit and composed of plurality of minute columnar portions, which are separate from each other or at least partially connected to each other, and with a light reflecting thin film provided over the projecting and depressed structures. The reflective display device has a liquid crystal layer provided between a pair of substrates. One of the pair of substrates is provided with projecting and depressed portions covered with a metal film and with a support portion for supporting the counter substrate, which are molded integrally. Yamanaka et al. fail to disclose the required projecting and depressions, the required shape configuration, the required shape configuration in the required manner and the required polygon and pixel structure. However, Jang et al. disclose a reflection type liquid crystal display and a method for fabricating the same where the required projecting and depression structure are disclosed. Furthermore, Goto et al. disclose a light guide plate, surface light source using the light guide plate and liquid crystal display device where the

Art Unit: 2826

required shape structure is disclosed. Korishima et al. disclose a liquid crystal display structure where the required shape structure in the required manner is disclosed. Tsuda et al. disclose a reflector, reflective liquid crystal, display incorporating the same and method for fabricating the same where the required pixel and polygon structure are disclosed.

It would have been obvious to one of having ordinary skill in the art at the time the invention was made to include the required projecting and depression structures, the required shape structure, the required shape structure in the required manner and the pixel structure and polygon in Yamanaka et al. as taught by Jang et al., Goto et al., Korishima et al., and Tsuda et al. respectively in order to have a liquid crystal display device with better performance.

#### Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Page 6

Application/Control Number: 10/024,782

Art Unit: 2826

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

FE April 19, 2004

Minhloan Tran

Minhloan Tran
Primary Examiner
Art Unit 2826